

## Electronic supplementary information

# Highly uniform and vertically aligned SnO<sub>2</sub> nanochannel arrays for photovoltaic applications

Jae-Yup Kim,<sup>‡a</sup> Jin Soo Kang,<sup>‡bc</sup> Junyoung Shin,<sup>c</sup> Jin Kim,<sup>bc</sup> Seung-Joo Han,<sup>d</sup> Jongwoo Park,<sup>a</sup>  
Yo-Sep Min,<sup>d</sup> Min Jae Ko<sup>\*aef</sup> and Yung-Eun Sung<sup>\*bc</sup>

<sup>a</sup>Photo-electronic Hybrids Research Center, Korea Institute of Science and Technology (KIST), Seoul 136-791, Republic of Korea.

<sup>b</sup>Center for Nanoparticle Research, Institute for Basic Science (IBS), Seoul 151-742, Republic of Korea.

<sup>c</sup>School of Chemical and Biological Engineering, Seoul National University, Seoul 151-742, Republic of Korea.

<sup>d</sup>Department of Chemical Engineering, Konkuk University, Seoul, 143-701, Republic of Korea

<sup>e</sup>Green School, Korea University, Seoul 136-701, Republic of Korea.

<sup>f</sup>KU-KIST Graduate School of Converging Science and Technology, Korea University, Seoul 136-701, Republic of Korea.

<sup>‡</sup>These authors contributed equally to this work.

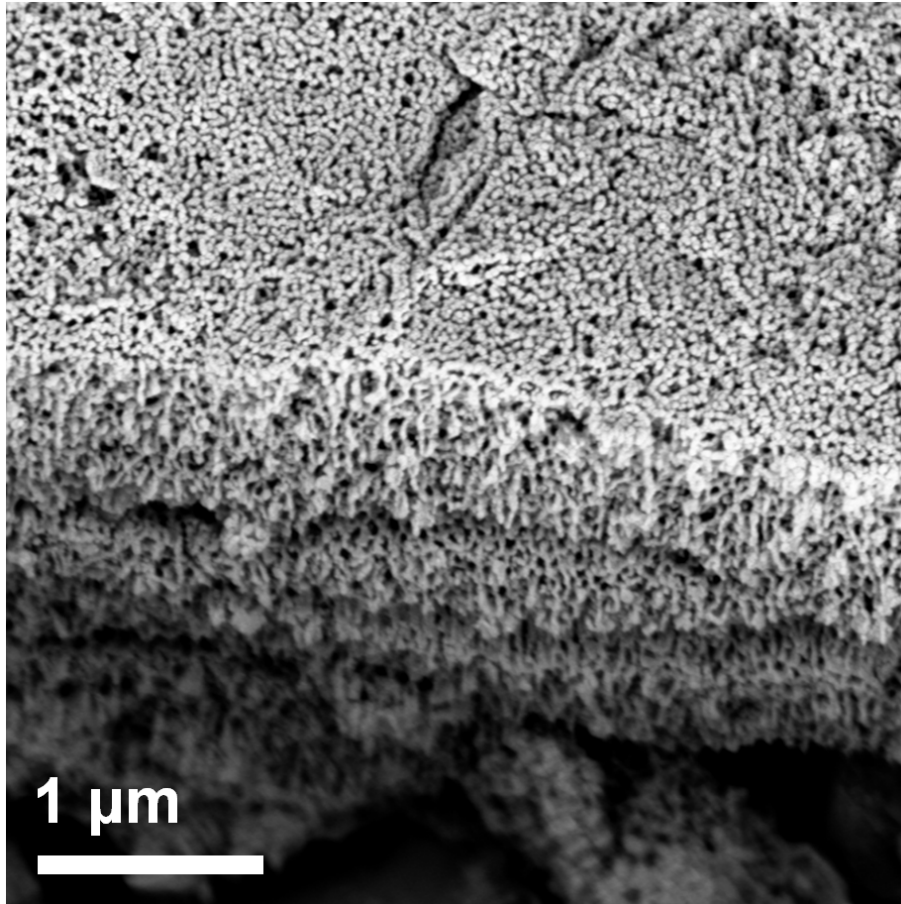
### \*CORRESPONDING AUTHORS

Yung-Eun Sung

Tel: +82-2-880-1889; fax: +82-2-888-1604; e-mail address: ysung@snu.ac.kr

Min Jae Ko

Tel: +82-2-958-5518; fax: +82-2-958-6649; e-mail address: mjko@kist.re.kr



**Fig. S1.** FE-SEM image of annealed SnO<sub>2</sub> nanochannel arrays prepared by the conventional anodic oxidation process (This image was obtained after tilting the edge side of prepared sample during the FE-SEM analysis).

**Table S1.** Summary of  $J$ - $V$  characteristics of the SnO<sub>2</sub> nanochannel electrodes for different anodic oxidation times.

anodic oxidation time (sec)	thickness of nanochannel ( $\mu\text{m}$ )	$J_{\text{sc}}$ ( $\text{mA}/\text{cm}^2$ )	$V_{\text{oc}}$ (mV)	$FF$ (%)	$\eta$ (%)
210	4.0	3.92	535	33.38	0.70
		3.49	550	34.38	0.66
		3.10	565	34.83	0.61
270	6.0	5.73	545	31.06	0.97
		5.64	555	31.31	0.98
		4.99	575	36.59	1.05
330	7.0	6.81	560	34.09	1.30
		6.85	550	33.18	1.25
		6.51	570	35.30	1.31
390	6.4	5.65	550	35.40	1.10
		5.99	560	29.22	0.98
		5.05	560	36.78	1.04

**Table S2.** Summary of the  $J$ - $V$  characteristics of the SnO<sub>2</sub>/TiO<sub>2</sub> nanochannel electrodes for different number of TiO<sub>2</sub> atomic layer deposition cycles.

ALD cycles	$J_{sc}$ (mA/cm <sup>2</sup> )	$V_{oc}$ (mV)	$FF$ (%)	$\eta$ (%)
0 cycle-1	6.81	560	34.09	1.30
0 cycle-2	6.85	550	33.18	1.25
0 cycle-3	6.51	570	35.30	1.31
3 cycles-1	5.15	510	32.74	0.86
3 cycles-2	5.84	485	35.31	1.00
3 cycles-3	5.00	490	34.69	0.85
6 cycles-1	4.59	515	37.65	0.89
6 cycles-2	4.78	490	33.73	0.79
6 cycles-3	5.66	495	33.19	0.93
15 cycles-1	8.55	570	32.83	1.60
15 cycles-2	7.90	545	34.37	1.48
15 cycles-3	7.68	565	35.26	1.53
30 cycles-1	6.45	605	32.80	1.28
30 cycles-2	6.45	590	32.85	1.25
30 cycles-3	6.49	590	34.21	1.31